

PATENT**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

Applicant: Chao-Hu Liang, Examiner: MAI, ANH D
Chih-Hung Chen,
Yu-Shan Tai
Po-Lun Cheng

Filing Date: 03/25/2002 Art Unit: 2814
Serial No.: 10/063,128 Docket No.: NAUP0385USA

Title: METHOD OF FORMING A POLYSILCON LAYER

To: Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Subject: Response to the Office Action dated 09/02/2003

Dear Sir/Madam:

INTRODUCTORY COMMENTS

In response to the Office Action identified above,
the arguments are indicated in the following section.
Consideration of all arguments is politely requested.

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